

# MNC 2020



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## ABSTRACT DEADLINE

**June 29, 2020**

**November 9-12, 2020**

**Art Hotel Osaka Bay Tower, Osaka, Japan**

## CONFERENCE SCOPE

- 1: Lithography and Related Technologies and Metrology
  - 1-1: Photolithography and Patterning
  - 1-2: Electron and Ion Beam Technologies
  - 1-3: Resist and Directed Self-Assembly
- 2: Nanotechnology
  - 2-1: Nanocarbons
  - 2-2: Nanodevices
  - 2-3: Nanofabrication
  - 2-4: Inorganic Nanomaterials
  - 2-5: Organic Nanomaterials
  - 2-6: NanoTool
- 3: Nanoimprint, Hybrid-NIL, Biomimetics, and Functional Surfaces
- 4: BioMEMS, Lab on a Chip, and Nanobiotechnology
- 5: Microsystem Technology and MEMS
- 6: Atomic Layer Processing (ALP)

## COMMITTEE CHAIRS

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